

# an anomalously large photovoltage effect in antimony orthoniobate

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(Submitted March 25, 1976)

*Pis'ma Zh. Eksp. Teor. Fiz.* **23**, No. 9, 522-523 (5 May 1976)

Observations and investigations were made of the effect of anomalously large photovoltages (the APV effect) in single crystals of the ferroelectric antimony orthoniobate. The photo-emf in  $\text{SbNbO}_4$  in the [001] direction exceeds the width of the forbidden band ( $E_g \approx 3$  eV) by one order of magnitude.

PACS numbers: 72.40.+w

It is known that the photo-emf in semiconductors, regardless of its nature, does not exceed the width of the forbidden band, i. e., several volts. The only exceptions are semiconducting textures, in which an anomalously large photovoltage effect (APV effect) is observed; this effect is due to the superposition of the elementary photo-emf that develop across the  $p$ - $n$  junctions of the texture.<sup>[1]</sup>

We have observed the APV effect in single crystals of the ferroelectric

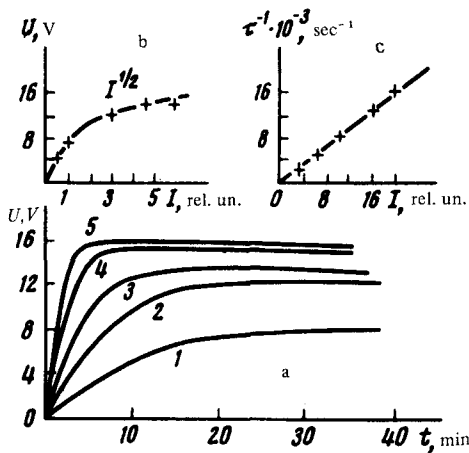


FIG. APV effect in antimony orthoniobate: a) Kinetics of the APV effect at various light intensities  $I$ . Curves 1—5 correspond to light intensities  $I=0.02, 0.06, 0.12, 0.2,$  and  $0.4$  W/cm $^2$ . b) Dependence of  $v(\tau)$  on  $I$ ; c) Dependence of  $\tau$  on  $I$ .

antimony orthoniobate. The  $\text{SbNbO}_4$  crystals were illuminated with an argon laser (488 nm) in the spontaneous-polarization direction [001]. The photo-emf  $v$  was measured in the same direction. The photo-emf in the perpendicular direction was negligibly small. The measurement results are shown in Figs. a, b, and c. When the light is turned on, the photo-emf  $v$  increases within a time  $\tau$  to a stationary value  $v(\tau)$  that depends on the light intensity  $I$  (Fig. a). After the light is turned off,  $v$  remains constant. The pyroeffect is negligible and has no influence on the measurement of  $v$ . Figure b shows a plot of  $v(\tau)$  against  $I$ ; at small  $I$  this plot is close to  $I^{1/2}$ , and it is seen from Fig. c that the time  $\tau$  is inversely proportional to  $I$ .

These results show that the photo-emf in  $\text{SbNbO}_4$  in the [001] direction exceeds by one order of magnitude the width of the forbidden band ( $E_g \approx 3$  eV), and seems to be limited by the crystal thickness  $L$  in this direction ( $L \approx 0.02$  cm). It can be assumed that the APV effect in  $\text{SbNbO}_4$  belongs to the class of photo-ferroelectric phenomena<sup>[2,3]</sup> that have the same mechanism as the so-called optical distortion, which constitutes a photo-induced change of the birefringence  $\Delta n$ .<sup>[4,5]</sup> In this case optical charge exchange of the centers, due to the nonequilibrium conductivity, changes the spontaneous induction by an amount  $\Delta D$ , leads to formation of a depolarization field  $E = \Delta D/\epsilon$  and of a photo-emf  $v = (\Delta D/\epsilon)L$ . For  $\epsilon \approx 240$ ,<sup>[6]</sup>  $L \approx 0.02$  cm, and  $\Delta D \approx 10^{-6}$  C/cm $^2$  (this value corresponds to saturation of the optical-distortion effect in the lithium niobate<sup>[4,5]</sup>) we have  $v = 75$  V, which is close to the experimentally measured values of the photo-emf. Unfortunately, the antimony orthoniobate crystals grown by the hydrothermal method<sup>[6]</sup> were in the shape of thin plates with advanced face (001), so that the effect of the optical distortion  $\Delta n$  in the [100] direction could not be observed and it was impossible to estimate  $\Delta D$  independently. However, the similar character of the functions  $\Delta n = \Delta n(I)$  and  $v = v(I)$ , the  $\tau = \tau(I)$  dependence, and our estimates, all confirm the assumption that APV effect in  $\text{SbNbO}_4$  and the optical distortion are governed by a common mechanism.

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